



Patent  
Atty DKT No. AMAT/5844/CMP/CMP/RKK

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## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Chen et al.

Serial No.: 10/033,732

Filed: December 27, 2001

Confirmation No. Unknown

For: Conductive Polishing Article  
For Electrochemical Mechanical  
Polishing

Assistant Commissioner for Patents  
Washington, D.C. 20231

Dear Sir:

### PRELIMINARY AMENDMENT

Prior to examining the above-referenced application, the Applicants request the application be amended as follows.

### IN THE SPECIFICATION

Please replace the paragraph [0001] with the following paragraph:

[0001] This application is a continuation-in-part of co-pending United States Patent Application No. 09/505,899 (AMAT/4100), filed on February 17, 2000, <sup>and</sup> a continuation-in-part of co-pending United States Patent Application No. 10/026,854 (AMAT/5765), filed on December 20, 2001; and claims benefit of United States Provisional Patent Application Serial Number 60/286,107, filed April 24, 2001, (AMAT 5844L) and United States Provisional Patent Application Serial Number 60/326,263,